

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/749,134	12/30/2003	Angelo Magri'	02CT20753422	3843	
	7590 11/17/2005	EXAMINER			
ALLEN, DYER, DOPPELT, MILBRATH & GILCHRIST P.A. 1401 CITRUS CENTER 255 SOUTH ORANGE AVENUE			MANDALA, VICTOR A		
P.O. BOX 379			ART UNIT	PAPER NUMBER	
ORLANDO, I	ORLANDO, FL 32802-3791				
			DAME SALES OF ALLES	DATES SALVED 11/18/2005	

DATE MAILED: 11/17/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

				H			
		Application No.	Applicant(s)				
·		10/749,134	MAGRI' ET AL.				
10	Office Action Summary	Examiner	Art Unit				
	_	Victor A. Mandala Jr.	2826				
Period fo	The MAILING DATE of this communication app or Reply	ears on the cover sheet with the c	orrespondence address				
	ORTÉNED STATUTORY PERIOD FOR REPLY	/ IS SET TO EVOIDE AMONTH	C) OP THIRTY (20) DAVO				
WHI(- Exte after - If NC - Failu Any	CHEVER IS LONGER, FROM THE MAILING DAISING DAI	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tin rill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	N. nely filed the mailing date of this communicatio D (35 U.S.C. § 133).				
Status							
1)[Responsive to communication(s) filed on <u>08 No</u>	ovember 2005.		,			
•	This action is FINAL. 2b) This action is non-final.						
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
	closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 45	i3 O.G. 213.				
Disposit	ion of Claims						
4)⊠	Claim(s) 24-38 and 40-50 is/are pending in the	application.	•				
4a) Of the above claim(s) is/are withdrawn from consideration.							
5) Claim(s) is/are allowed.							
6)⊠	Claim(s) <u>24-26,38,40 and 41</u> is/are rejected.	•					
·	Claim(s) <u>27-37 and 42-50</u> is/are objected to.						
8)[]	Claim(s) are subject to restriction and/or	election requirement.	•				
Applicati	ion Papers						
9)[The specification is objected to by the Examine	r.					
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).							
11)	The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form PTO-152.				
Priority u	ınder 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of:							
	1.☐ Certified copies of the priority documents have been received.						
	2. Certified copies of the priority documents have been received in Application No						
	3. Copies of the certified copies of the prior		d in this National Stage				
	application from the International Bureau	• • • • • • • • • • • • • • • • • • • •					
* S	See the attached detailed Office action for a list of	of the certified copies not receive	d.				
Attachman	*/~)						
Attachment	t(s) e of References Cited (PTO-892)	4) Interview Summary	(PTO_413)				
2) Notice	e of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail Da	te				
	nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) r No(s)/Mail Date <u>8/8/05</u> .	5) Notice of Informal Pa . Other:	atent Application (PTO-152)				

Application/Control Number: 10/749,134

Art Unit: 2826

DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 24-26, 38, 40, and 41 are rejected under 35 U.S.C. 102(b) as being anticipated by Japan Patent Office Publication No. 01005070 Abstract, Yamamoto.

- 1. Referring to claim 24, a method for forming a vertical-conduction and planar-structure MOS device having a double thickness gate oxide, (#6), the method comprising: forming spaced apart active areas in a semiconductor substrate and defining a JFET area, (#9-2, 8-2, 2, & 1), there between, the JFET area, (#9-2, 8-2, 2, & 1), also forming a channel, (area under #6), between the spaced apart active areas; forming a gate oxide, (#6), on the semiconductor substrate, (#1&2), and comprising forming a first portion having a first thickness, (area of #6 that is thinner), on the active areas and at a periphery of the JFET area, (#9-2, 8-2, 2, & 1), and forming a second portion having a second thickness, (area of #6 that is thicker), on a central area of the JFET area, (#9-2, 8-2, 2, & 1), the second thickness being greater than the first thickness and forming an enrichment region, (#5'), in the JFET area, (#9-2, 8-2, 2, & 1), under the second portion of the gate oxide, (area of #6 that is thicker).
- 2. Referring to claim 25, a method according to Claim 24, wherein the enrichment region is self-aligned with the second portion of the gate oxide, (area of #6 that is thicker).

Art Unit: 2826

- 3. Referring to claim 26, a method according to Claim 24, wherein an interface between the first, (area of #6 that is thinner), and second portions, (area of #6 that is thicker), of the gate oxide has a tapered thickness.
- 4. Referring to claim 38, a method for forming a semiconductor device comprising: forming spaced apart source, (#9-2), and drain areas, (#9-1), in a semiconductor substrate, (#1&2), and defining a JFET area, (#9-2, 8-2, 2, & 1), there between, the JFET area, (#9-2, 8-2, 2, & 1), also forming a channel, (area under #6), between the source, (#9-2), and drain areas, (#9-1); forming a gate oxide, (#6), on the semiconductor substrate, (#1&2), and comprising forming a first portion having a first thickness, (area of #6 that is thinner), on the , (#9-2), and drain areas, (#9-1), and at a periphery of the JFET area, (#9-2, 8-2, 2, & 1), forming a second portion having a second thickness, (area of #6 that is thicker), on a central area of the JFET area, (#9-2, 8-2, 2, & 1), the second thickness being greater than the first thickness, (area of #6 that is thinner), and forming an enrichment region, (5'), in the JFET area, (#9-2, 8-2, 2, & 1), under the second portion of the gate oxide, (area of #6 that is thicker).
- 5. Referring to claim 40, a method according to Claim 38, wherein the enrichment region, (5'), is self-aligned with the second portion of the gate oxide, (area of #6 that is thicker).
- 6. Referring to claim 41, a method according to Claim 38, wherein an interface between the first, (area of #6 that is thinner), and second portions of the gate oxide, (area of #6 that is thicker), has a tapered thickness.

Application/Control Number: 10/749,134

Art Unit: 2826

Allowable Subject Matter

7. Claims 27-37 and 42-50 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

Conclusion

Applicant's submission of an information disclosure statement under 37 CFR 1.97(c) with the fee set forth in 37 CFR 1.17(p) on 8/8/05 prompted the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE**FINAL. See MPEP § 609.04(b). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Victor A. Mandala Jr. whose telephone number is (571) 272-1918. The examiner can normally be reached on Monday through Thursday from 8am till 6pm.

Art Unit: 2826

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nathan J. Flynn can be reached on (571) 272-1915. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

VAMJ 11/08/05

> NATHAN J. FLYNN SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800